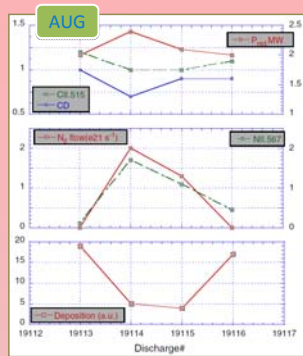
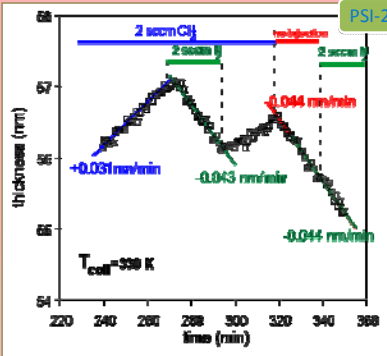


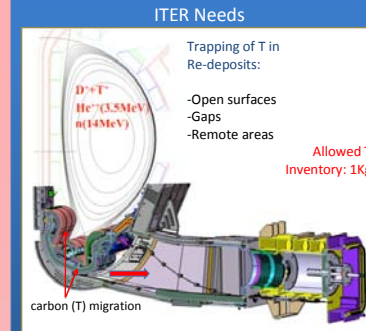
Motivation

- Tritium retention by carbon co-deposits is an important concern in ITER: Only W/Be for active phase proposed
- New techniques are necessary for the removal of these co-deposits: Avoid T₂O formation, cleaning of Gaps, material mixing,.....
- Recovery from cleaning: Impact of techniques in T processing Plant, wall oxidation, in-vessel components,....
- Gas phase reactions of nitrogen or nitrogen containing species with the C film growth precursor: Formation of non-reactive species that can be pumped away.

SCAVENGERS (inhibition)



W. Bohmeyer et al. J. Nucl. Mater. s2009, 390-391:560



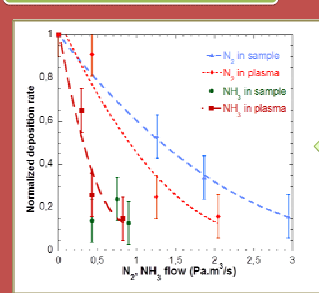
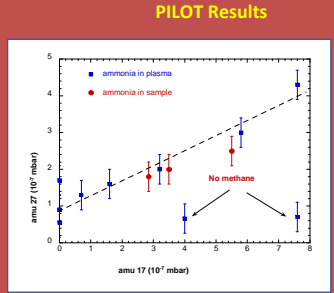
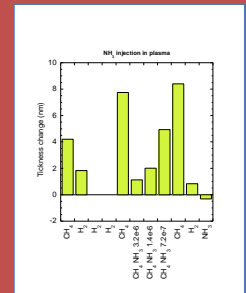
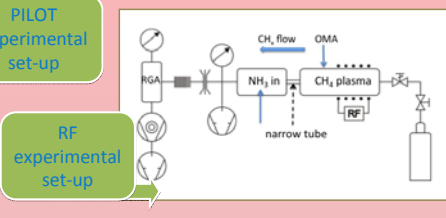
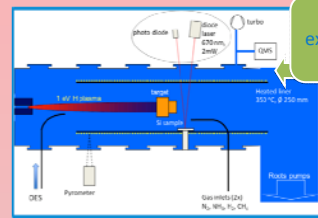
Recent ERO estimates

A. Kirschner et al./Journal of Nuclear Materials 390-391 (2009) 152-155

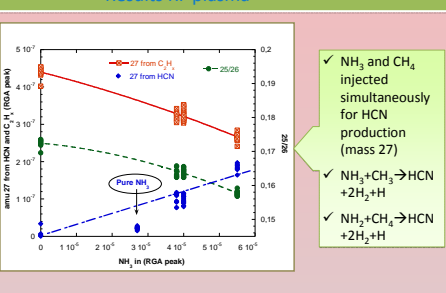
Estimated carbon and beryllium deposition and tritium retention rates.

Carbon layers	Beryllium layers		Σ
	On target (T/C=0.05)	Remote (T/C=0.5)	
(a) Inner divertor			
HMM	8.0e19 C/s	2.4e22 Be/s	5.0e20 Be/s
TRIM	0.02 mg T/s	0.1 mg T/s	0.1 mg T/s
(b) outer divertor			
HMM	8.7e20 C/s	3.0e20 C/s	3.84e21 Be/s
TRIM	7.0e20 C/s	7.0e20 C/s	6.0e19 Be/s
	0.2 mg T/s	1.8 mg T/s	1.0 mg T/s

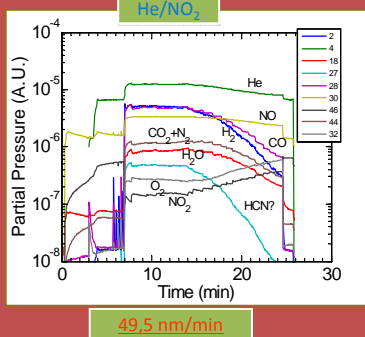
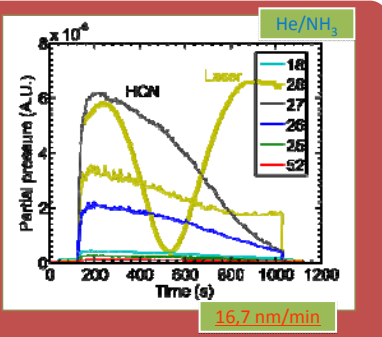
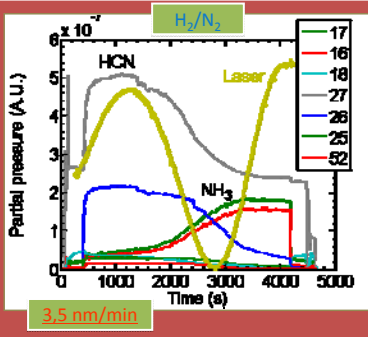
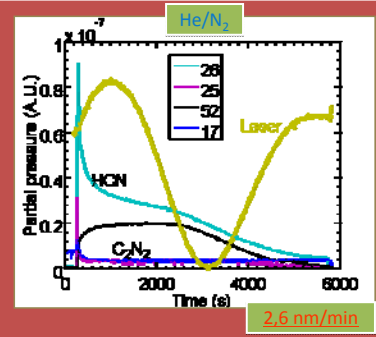
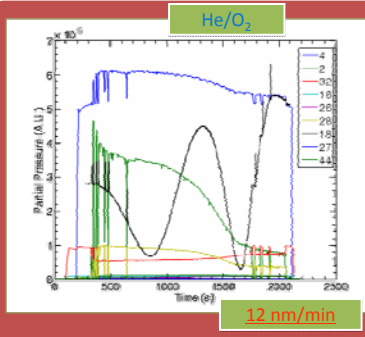
T Inventory: 200-50 shots
-Scavengers
-GD/Cleaning
-Thermo-oxidation



✓ Inhibition effect in a set of experiments with different ammonia injections.
✓ N₂ → 2-3 higher fluxes for same effect

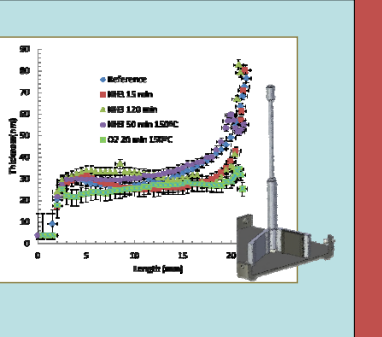
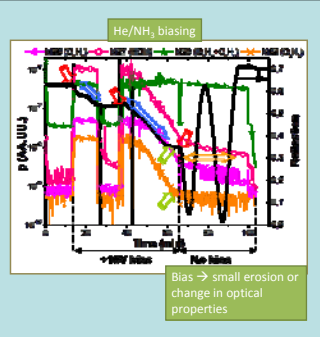


Plasma Cleaning of C:H films: O₂, N₂, NH₃ and NO₂

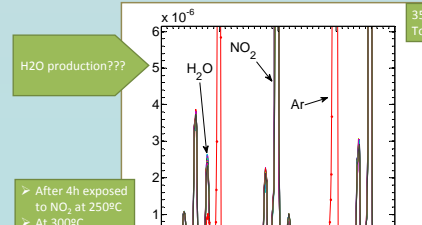
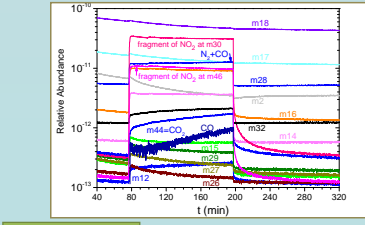


Plasmas in Gaps:

- ✓ Same setup as in I. Tamarro, J. Ferreira, V. Herrero, F. Tabarés, C. Gómez-Alexandre, J. Nucl. Mater. 390-391 (2009) 696-700.
- ✓ Thickness measured by laser interferometry. He/NH₃ plasmas for cleaning
- ✓ No dependence of the NH₃ erosion with time → Observed erosion due to changes in optical properties?
- ✓ No erosion observed at 150°C (NH₃) nor room temperature with NO₂
- ✓ Erosion successfully measured for He/O₂ cleaning
- ✓ High erosion rates in open surfaces in NH₃ and NO₂. No erosion in surface at floating potential → Mechanism involving ions!! (RF plasmas can do it better???)



Thermo-oxidation: O2 vs NO2



H₂O production???

- After 4h exposed to NO₂ at 250°C
- At 300°C completely clean after only 1h
- O₂ <100 nm/h at 400°C

Conclusions

- ✓ Nitrogen Chemistry highly suited for carbon deposition control in ITER with CFC targets. Integrated scenario to control T inventory. Scavenger during operation, plasma cleaning for open surfaces (independent of temperature) and thermo-oxidation to clean gaps in tiles.
- ✓ NH₃ injection demonstrated in PILOT-PSI
- ✓ NO₂ cleaning plasmas best results in open surfaces
- ✓ NO₂ Thermo-oxidation: Better than O₂ at T_w ~300°C
- ✓ But: Water production using NO₂, NH₃ and NO₂ DC plasmas don't clean in gaps